Topological flat bands in two-dimensional Cr doped AsH monolayers

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Discovery of two-dimensional (2D) topological insulators in such as group-V films initiates the enthusiasm to explore the exotic quantum states in low dimensions. Here, we perform first-principles calculations and tight-binding (TB) model to study the electronic properties in Cr dopped AsH monolayers(Cr@AsH). The Cr@AsH monolayer is found being a Chern metal (CM) with a nontrivial quasi-flat band appeared near the Fermi level (E_F). Interestingly, a clear band gap emerges near the E_F with a nonzero Chern number (C = -1). Under a small tensile strain (1.4% < ϵ < 2.05%), the monolayer changes to a Chern insulator (CI). Under a large strain (ϵ > 2.05%), the quasi-flat band interacts with the conduction Dirac band, leading to a phase transition and then the system become ferrovalley insulator(FVI) with zero Chern number(C = 0). The phase transition mechanism is comprehended by a tight-binding model built. The mechanism of phase transition is from different behaviors of band inversion in spin-up and spin-down subspace. Our results provide one type of candidate materials showing fractional Chern phenomena.



monolayer Cr@AsH.

Electronic properties

dxy/dx²-y² dyz/dxz dz²

Fig 2. Band structures with (a) and without

(b) spin-orbit coupling(SOC). (c-f) Atomic

resolved density of states(DOS).

Fig 3. (a-e) Band evolution under the tensile strain. The corresponding Berry curvatures (grey curves) are also shown. (f) Phase diagram of the monolayer under the strain.



Conclusions

- Cr@AsH is a Chern metal with a quasi-flat band appeared near the Fermi level in the ground state.
- Tensile strain can induce phase transitions in the materials from a Chern metal to a Chern insulator, half-valley metal, and ferrovalley insulator.
- The Cr@AsH monolayer is expected to show fractional Chern effects under tensile strain at the range of 1.4% < ε < 2.05%.

Reference: 1. Tong Zhou, Jiayong Zhang, et al. Nano Lett. 15, 5149–5155(2015) 2. Hao Huan, Yang Xue, et al. Phys. Rev. B 104, 165427 (2021)